

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of) Attorney Docket No.: **SOEI0021**
Ken SAWABE et al.)
Serial No.: 10/595,920) Confirmation No.: 9014
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For: PHOTORESISTIVE RESIN) Examiner: Unassigned
COMPOSITION, PHOTORESISTIVE)
ELEMENT, RESIST PATTERN) Date: September 15, 2006
FORMING METHOD AND PROCESS)
FOR MANUFACTURING PRINTED)
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SUBMISSION OF ENGLISH TRANSLATION OF
INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

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Sir:

Enclosed please find the English translation of the International Preliminary Report on Patentability (Chapter II) received from the International Bureau in the corresponding International Application No. PCT/JP2004/016255.

Respectfully submitted,

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